

In the Specification:

Please amend the paragraph at page 8, lines 15-22 as set forth below:

Next, a plasma film-forming apparatus that forms an interlayer insulation film by using a C_5F_8 gas including hydrogen atoms of 1×10^{-3} atomic % or less as a source gas is simply explained with ~~referent~~ reference to FIGS. 3 to 5. In the drawings, 61 represents a processing container (vacuum chamber), and 62 represents a stage including a temperature-adjusting means. The stage 62 is connected to a radio-frequency electric power source 63 of 13.56 MHz for imparting a bias, for example.